rtificate of Transmission Under 37 CFR1.8 I hereby certify that this correspondence is being facsimile transmitted to the U.S. Patent and Trademark Office (Fax. 703 (72 / 306) on

14/2004

Date

Name

Signature

This copy is also mailed to USPTO at the same time

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Wu-Niang Applicant

Art Unit: 1764

Feng

09/944,947

Examiner: DUONG, THANH P

Filed

Series No

09-01-2001

Title

Semiconductor waste-gas treating apparatus

being filth sedimentation-and

etching-proof

Mail Stop Non-Fee Amendment

Honorable Assistant Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Responsive to the Official Action date 06 / 28 / 2003, please amend the above-referenced Patent Application as following:

AMENDMENT